

FIG. I

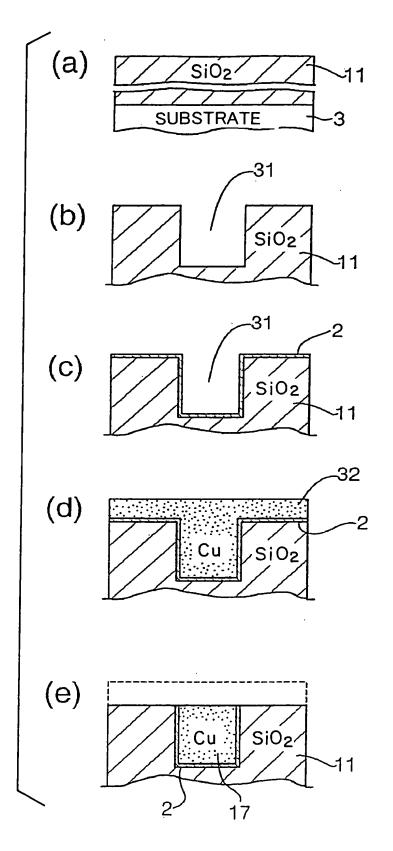


FIG. 2

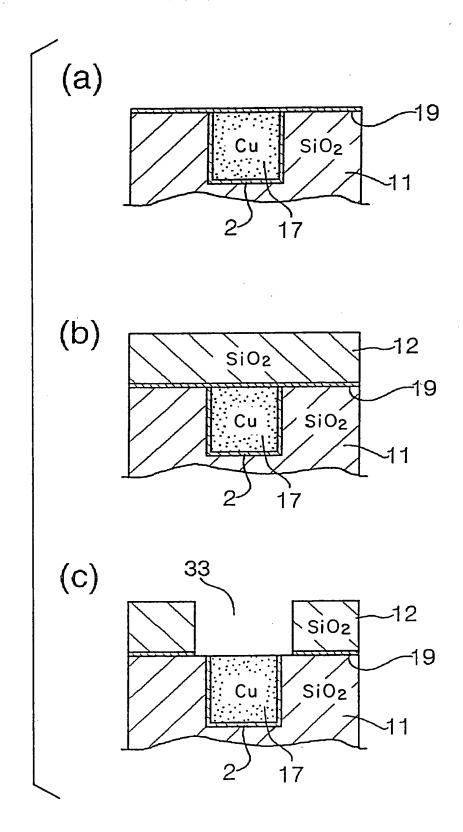


FIG. 3

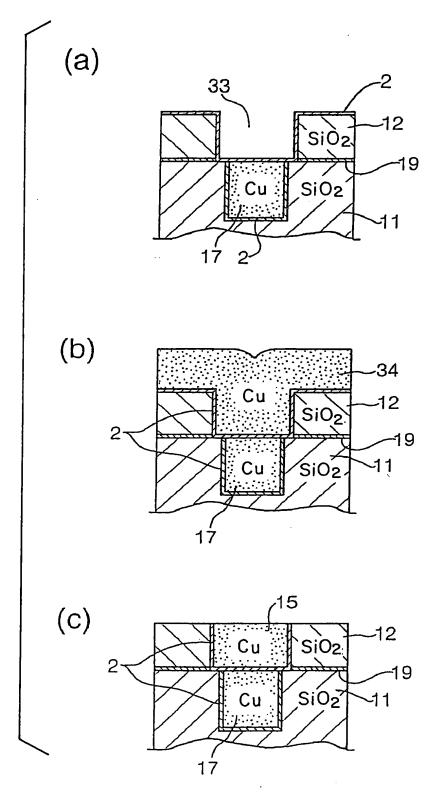
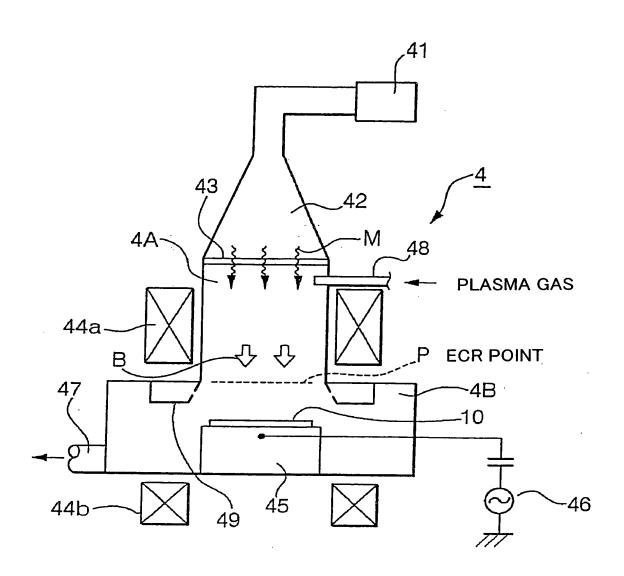
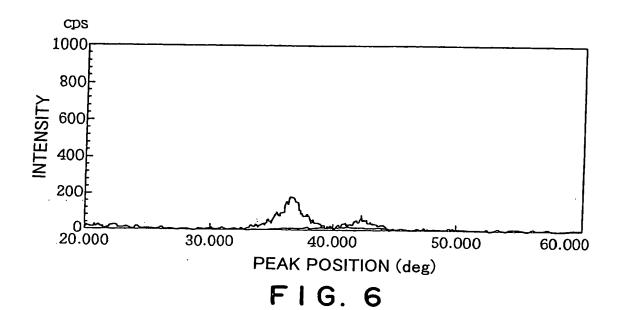
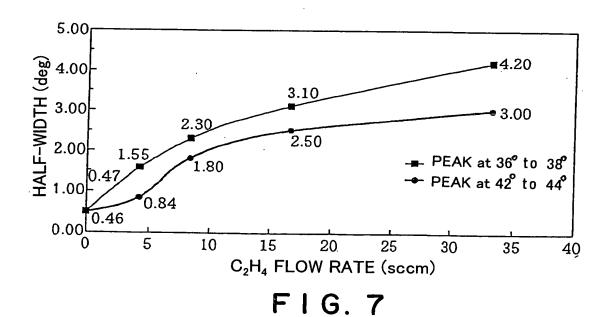


FIG. 4



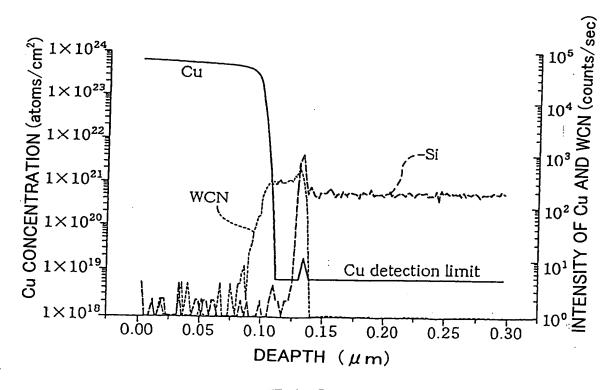
F1G. 5





C ₂ H ₄	HALF-WIDTH		BARRIER
FLOW RATE (SCCM)	FIRST PEAK	SECOND PEAK	PROPERTY
(SCCIVI)	·	SECOND PEAK	AGAINST Cu
0	0.46	0.47	0
4.2	1.55	0.84	0
8.3	2.30	1.80	0
16.7	3.10	2.50	. 🛆
33.3	4.20	3.00	×

FIG. 8



F1G. 9

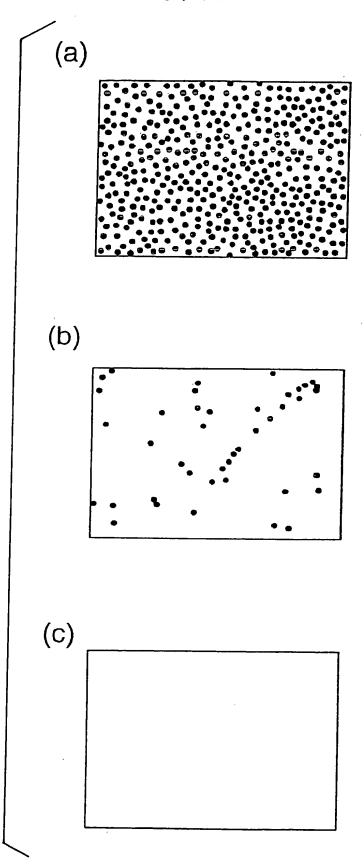
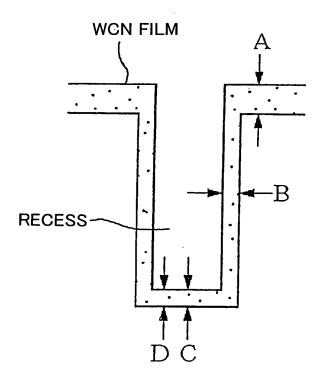


FIG. 10

	HALF-WIDTH		BARRIER
GAS	FIRST DEAK	SECOND DE M	PROPERTY
	FIRST PEAK		AGAINST Cu
C2H4	2.3	1.8	0
C2H6	3.2	2.6	\triangle
C2H2	1.9	1.6	0

FIG. II



F I G. 12

	COVERAGE (%)		
	B/A	C/A	D/A
WCN	20	32	28
WN	16	24	20

F1G. 13

	ADHESION STRENGH (psi)		
	SiO ₂ SiN		
WCN	4.5	4.2	
WN	2.3	1.8	

FIG. 14

N/W RATIO	C/W RATIO	ADHESION STRENGH TO SiO ₂ /SiN (kpsi)
0	0	<1/<1
0	0.48	5.0/4.7
0	0.79	6.2/5.1
0	0.98	5.4/3.7
0	1.23	5.4/4.2
0.48	0	2.3/1.8
0.49	0.12	4.0/3.7
0.47	0.24	4.5/4.2
0.42	0.34	6.2/5.2
0.4	0.54	4.2/3.9
0.39	0.75	5.1/4.2
0.32	0.98	6.1/3.4
0.79	0	2.1/1.2
0.78	0.3	2.8/1.8
0.74	0.41	2.1/2.4
0.7	0.62	2.6/2.0

FIG. 15

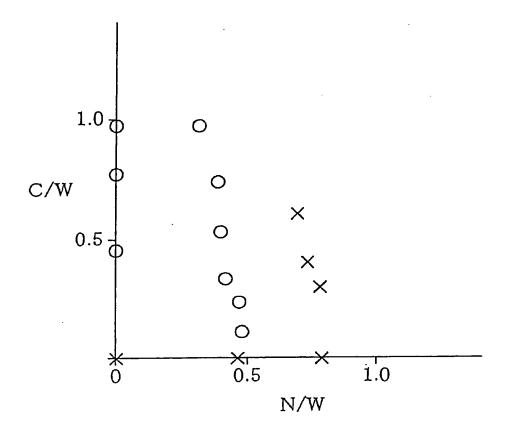
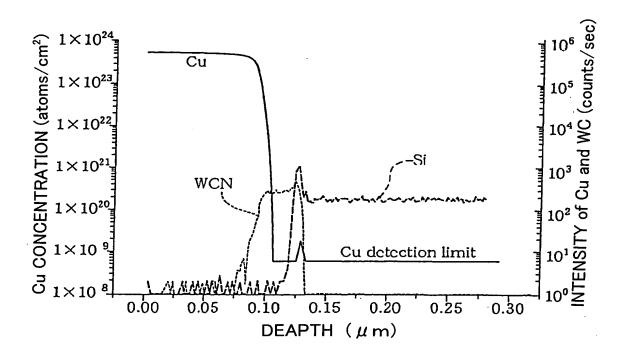


FIG. 16

CF4	Α.	В	С	D
0sccm	100%	16%	24%	20%
4.2sccm	100%	23%	36%	30%
8.3sccm	100%	. 27%	40%	34%
16.7sccm	100%	32%	45%	38%
C ₂ H ₄				
8.3sccm	100%	20%	32%	28%

F I G. 17



F I G. 18

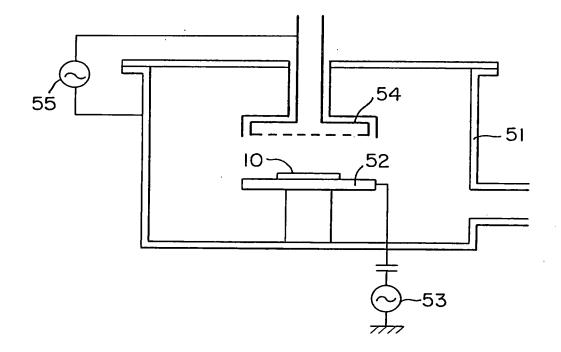


FIG. 19

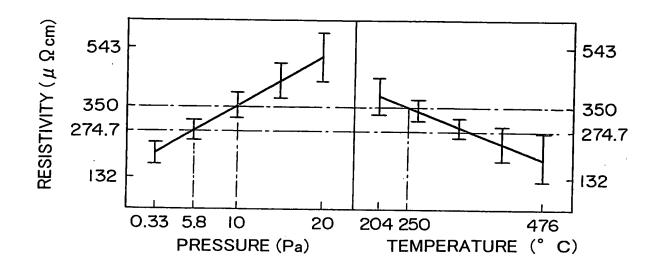


FIG. 20

RESISTIVITY	HALF-WIDTH		
$(\mu\Omega cm)$	FIRST PEAK	SECOND PEAK	
189	1.62	0.91	
275	2.31	1.65	
347	3.05	2.39	
420	4.02	2.98	
491	4.78	3.52	

FIG. 21